

Material	Dual e-Beam	Thermal e-Beam	Sputterer	PLD	Supplied by
Aluminum	X	X	X		UDNF
Aluminum Oxide	X	X	X		UDNF
Bismuth and Gallium Substituted Thulium Iron Garnet ($Tm_{2.5}Bi_{0.5}Fe_{3.8}Ga_{1.2}O_{12}$)				X	User
Bismuth and Gallium Substituted Thulium Iron Garnet ($Tm_{2.7}Bi_{0.3}Fe_{4.5}Ga_{0.5}O_{12}$)				X	User
Boron 10 (B10) >95%			X		User
Boron		X			User
Boron Carbide			X		User
Chromium	X	X	X		UDNF
Cobalt	X	X	X		UDNF
Cobalt/iron 90/10		X			UDNF
Cobalt/Iron/boron 60/20/20 % at 99.95%			X		UDNF
Copper	X	X	X		UDNF
Gallium Oxide/Bismuth Oxide				X	User
Germanium	X	X	X		Sputterer Target by User
Gold	X	X			UDNF
Iron		X	X		UDNF
Mo		X			User
MgO		X			User
Nickel	X	X	X		UDNF

Material	Dual e-Beam	Thermal e-Beam	Sputterer	PLD	Supplied by
Nickel/Chrome	X				User
Nickel/Iron 81/19	X	X	X		UDNF
Palladium	X	X			UDNF
Platinum	X	X	X		UDNF
Rhodium			X		User
Ruthenium	X	X			UDNF
Scandium			X		User
Silicon, p-type	X	X			UDNF
Silicon Carbide			X		UDNF
Silicon Nitride			X		User
Silicon monoxide		X			User
Silicon Dioxide	X	X	X		UDNF
Silver	X	X			UDNF
Tantalum	X	X			UDNF
Terbium Iron Garnet ($Tb_3Fe_5O_{12}$)				X	User
Thulium Iron Garnet ($Tm_3Fe_5O_{12}$)				X	User
Tin Oxide			X		UDNF
Titanium	X	X	X		UDNF
Titanium Oxide	X	X	X		UDNF
Tungsten			X		UDNF
Tungsten Oxide	X	X			UDNF
Vanadium Pentoxide				X	User
Vanadium pentoxide/Tungsten Dioxide				X	User
Yttrium Iron Oxide (YIG)			X	X	UDNF

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Zirconium		X			User

Last Updated

1/23/2024